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(54) Resistors, methods of forming said resistors, and articles comprising said resistors.

(57) This invention concerns resistor compositions, methods of forming such resistor compositions, and articles comprising a substrate carrying such resistor compositions.

The resistor compositions of the invention comprise carbon particles embedded in a matrix formed from short chain-length phenolic resin, long chain-length phenolic resin, epoxy and, optionally filler.

The resistor compositions of the invention can be formed by mixing short chain-length phenolic resin, long chain-length phenolic resin, solvent, and, if present, filler with carbon particles to form a solution which is then mixed with the epoxy to form an ink. The ink is applied to a substrate to form a film thereon which is cured to evaporate solvent and to allow polymerization to occur thereby leaving the resistor composition on the substrate.





ΕP 84 30 8273

DOCUMENTS CONSIDERED TO BE RELEVANT				
Category		h indication, where appropriate, ant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Ct. 4.)
х	US-A-3 686 139 (I. LUBIN)		1,3,4, 6,8,9, 12-14,	H 01 C 7/00 H 01 C 17/06
	49 - column 4,	6; column 3, line line 4; column 6, mns 9-10; example	16	
А	US-A-2 825 702 SILVERSHER)	(H.I.	1,6,8, 9,12, 16	
	* Claims 1,2,5,6; column 2, line 70 - column 3, line 8; column 3, line 74 - column 4, line 3 *			
A	CHEMICAL ABSTRACTS, vol. 83, no. 2, 14th July 1975, abstract no. 20684t, Columbus, Ohio, US; & JP - A - 75 16 095 (TOKYO SHIBAURA ELECTRIC CO., LTD.) 20-02-1975 * Abstract *		1,9	TECHNICAL FIELDS SEARCHED (Int. CI 4)
				H 01 C
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_	The present search report has t	oeen drawn up for all claims		
Place of search		Date of completion of the search		Examiner
THE HAGUE 10		10-10-1985	DECAN	NIERE L.J.

CATEGORY OF CITED DOCUMENTS

X: particularly relevant if taken alone
 Y: particularly relevant if combined with another document of the same category
 A: technological background
 O: non-written disclosure

A O P intermediate document

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T: theory or principle underlying the invention
 E: earlier patent document, but published on, or after the filing date
 D: document cited in the application
 L: document cited for other reasons

&: member of the same patent family, corresponding document